## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: Miwa KOZAWA et al. Art Unit: 1795

Filed: November 25, 2003 Confirmation Number: 4454

For: PROCESS FOR FORMING RESIST PATTERN, SEMICONDUCTOR DEVICE

AND FABRICATION THEREOF

Attorney Docket Number: 032132

Customer Number: 38834

Examiner: Daborah Chacko Davis

## PETITION FOR EXTENSION OF TIME

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Application Number: 10/720,097

October 9, 2009

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated June 11, 2009 for one month from September 11, 2009 to October 11, 2009.

The amount of \$130.00 for the cost of the extension of time is being paid via electronic credit card payment. If any additional fees are due in connection with this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

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/Kenneth H. Salen/

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